



Tokyo Electron Trias High K CVD SN: C13833

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CVD System, 12" <45nm process Vintage 2010

2 Chambers: CVD & ALD Process: NiOx, HfOx

Trias cluster: 2 Loadports

LM: Front end

Main power distribution (MPD)

Transfer module, TM

EX reactor, PM2: Plasma capability: No

Includes: Ozonizer & H20 Box 2 Touch screens ozonizer

High-k CVD reactor PM4: Thermal based deposition Transformer box (Hi-K) option elec box:

Manuals & Spare parts included Machine is in absolute as good as new condition ex R&D facility

PM2: Hafnium Nickel Titanium Vanadium

PM4: Hafnium Nickel Titanium Ruthenium Strontium









